

Supporting Information

Fabrication of Nanoscale Ni/NiO Heterostructures as Electrocatalyst for Efficient Methanol Oxidation

Juan Wang,^a Detre Teschner,^b Yuanying Yao,^a Xing Huang,^{* b} Marc Willinger,^b
Lidong Shao,^{* a} and Robert Schlögl^b

^aShanghai Key Laboratory of Materials Protection and Advanced Materials in Electric Power, Shanghai University of Electric Power, Shanghai 200090, China. E-mail: lidong.shao@shiep.edu.cn

^bDepartment of Inorganic Chemistry, Fritz-Haber Institute of the Max Planck Society, Faradayweg 4-6, 14195 Berlin, Germany. E-mail: xinghuang@fhi-berlin.mpg.de

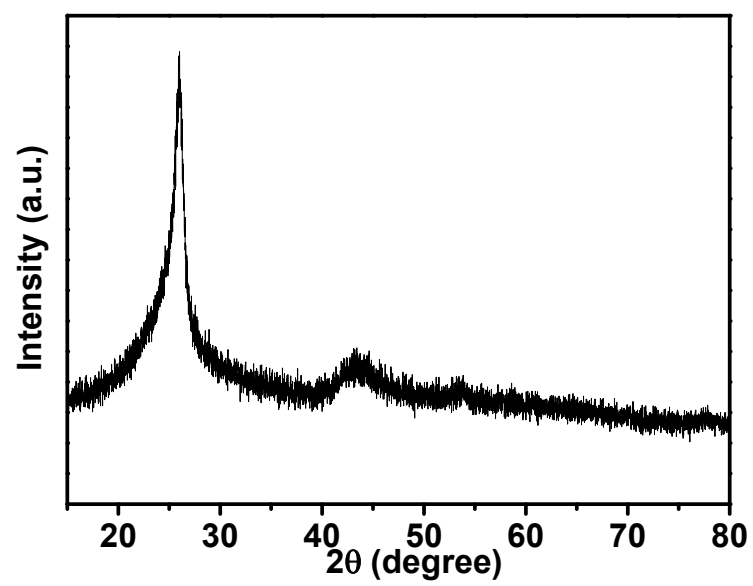
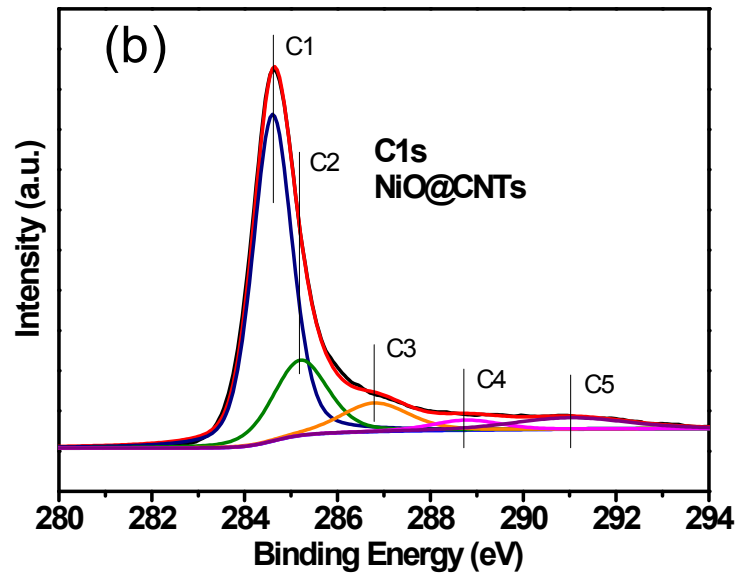
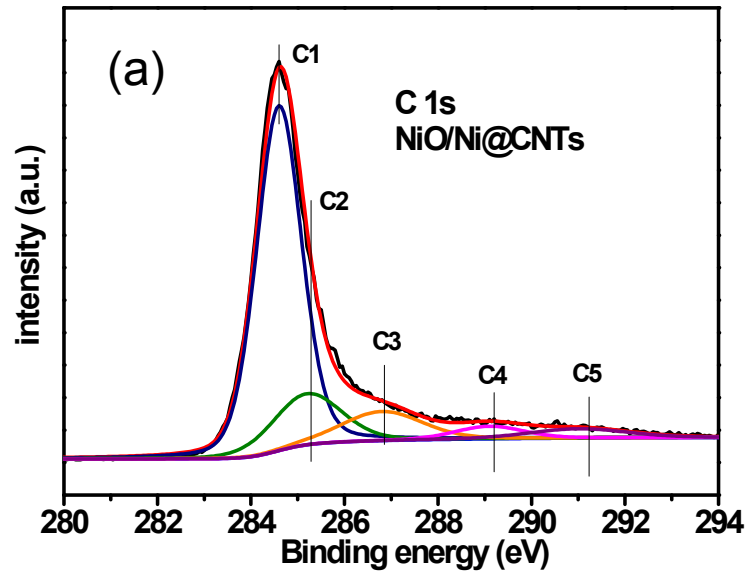


Figure S1. XRD pattern of OCNTs



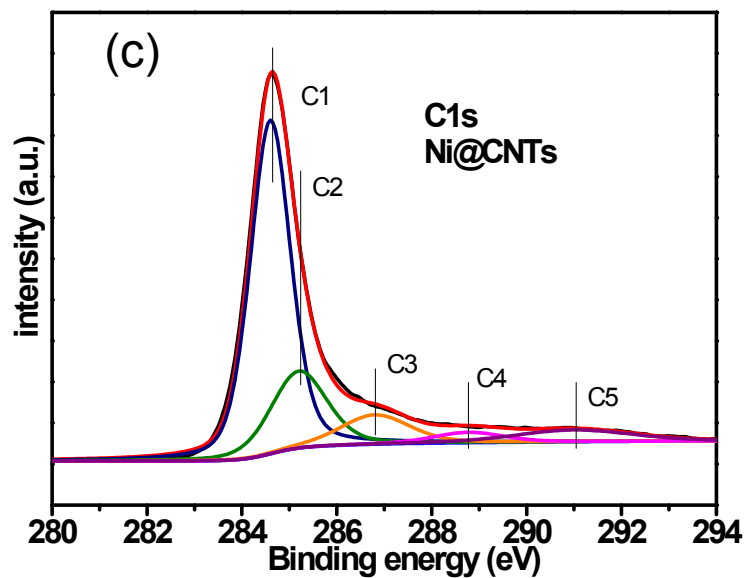
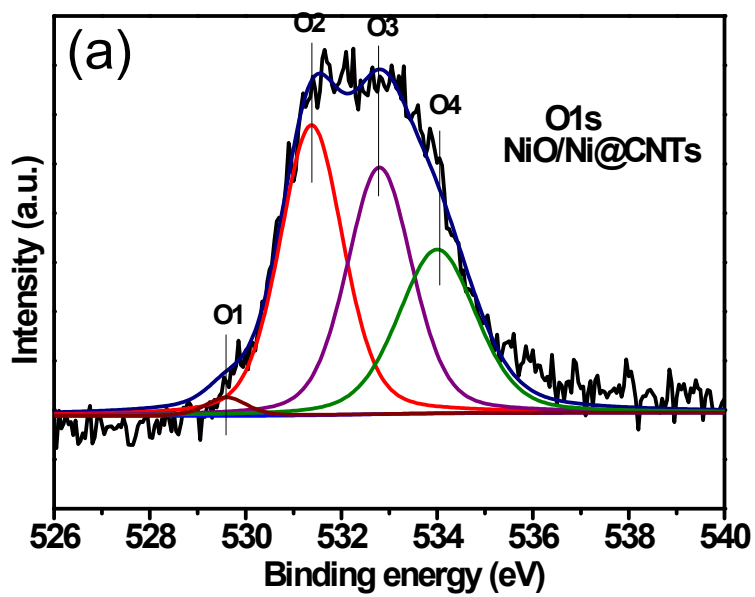


Figure S2. XPS C1s profile of NiO/Ni@CNTs (a), NiO@CNTs (b) and Ni@CNTs (c).



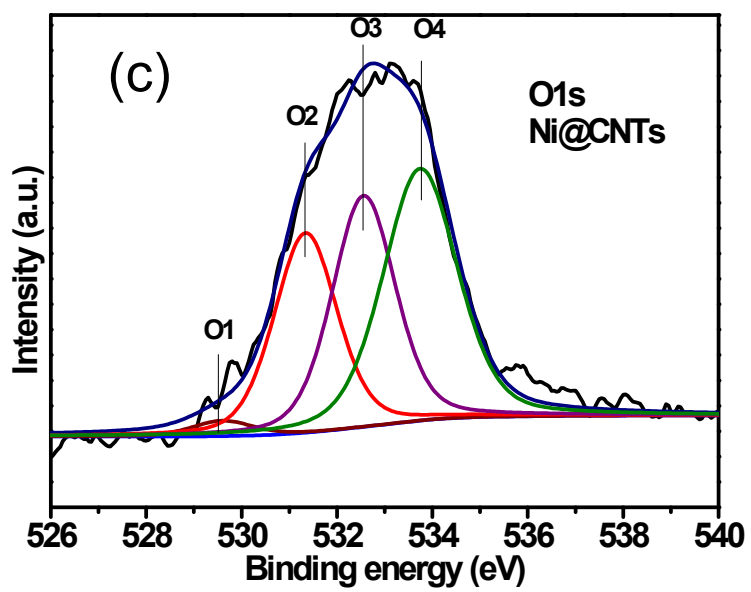
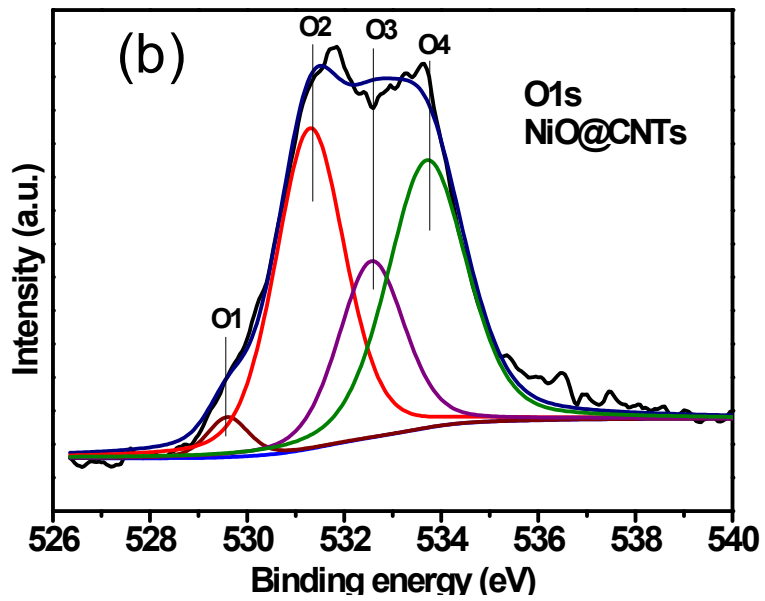


Figure S3. XPS O1s profile of NiO/Ni@CNTs (a), NiO@CNTs(b) and Ni@CNTs(c).

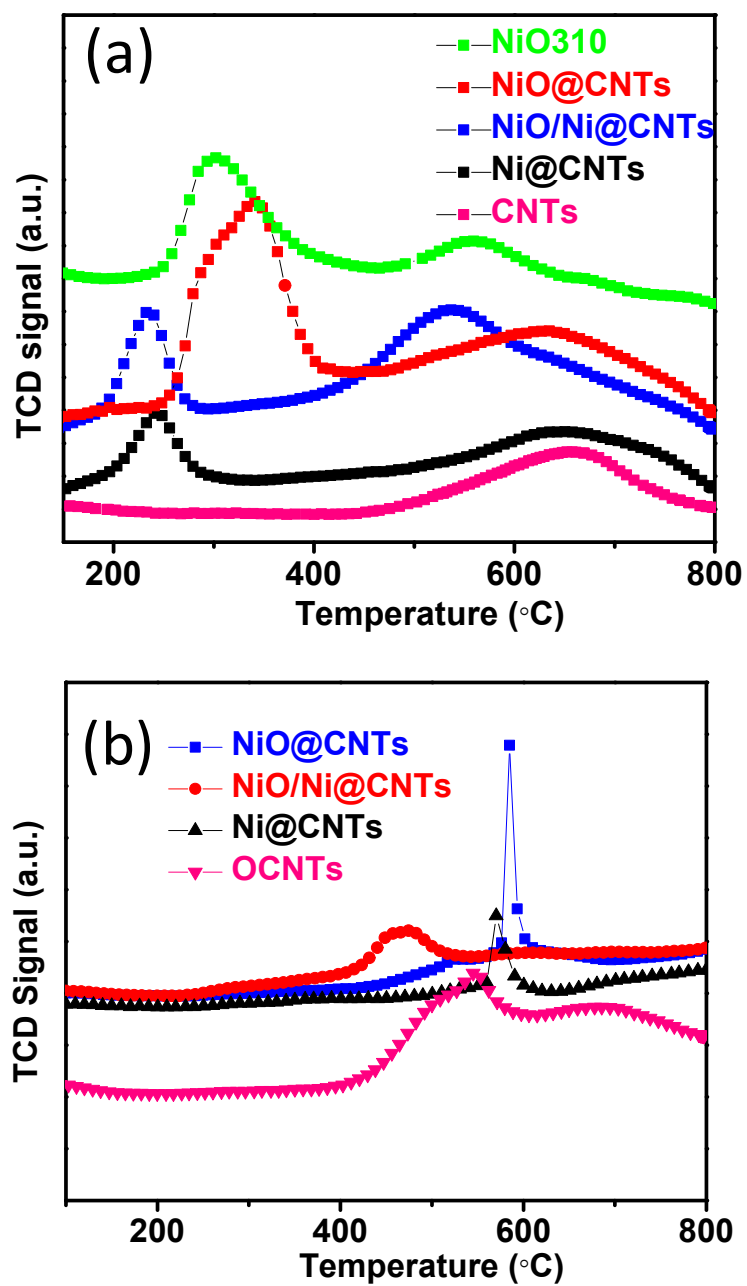
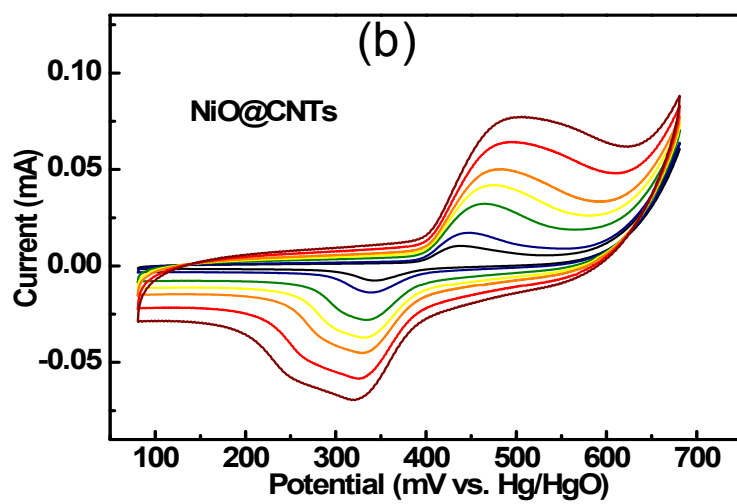
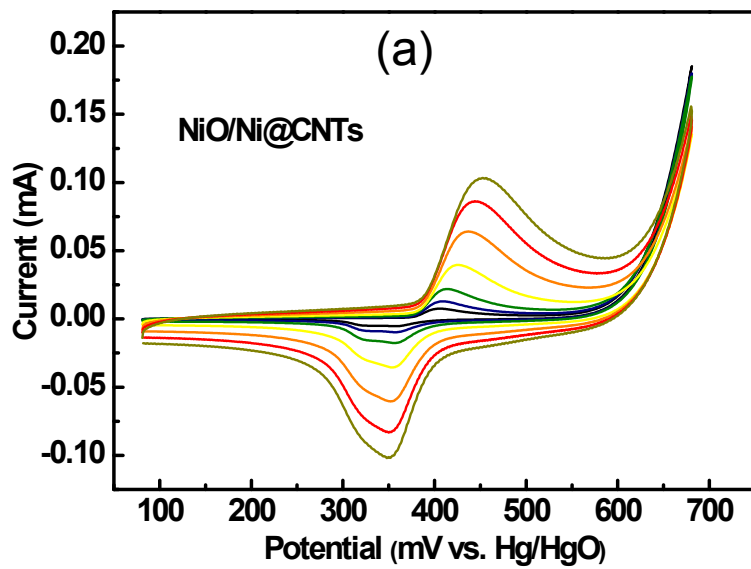


Figure S4. H₂-TPR profiles (a) and CO₂-TPD profiles (b) of the catalysts.



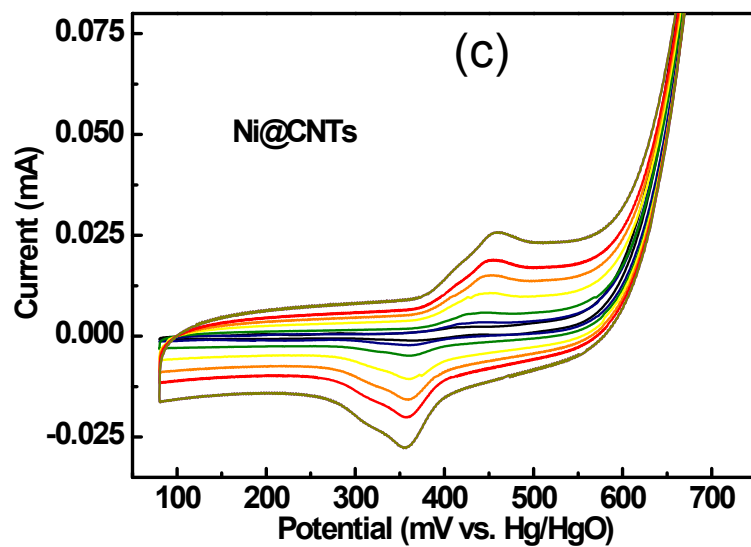


Figure S5. Cyclic voltammograms (CV) of NiO/Ni@CNTs (a), NiO@CNTs (b) and Ni@CNTs (c) in 1M KOH. Scan rate: 5, 10, 20, 50, 100, 150, 200 mV s^{-1} .

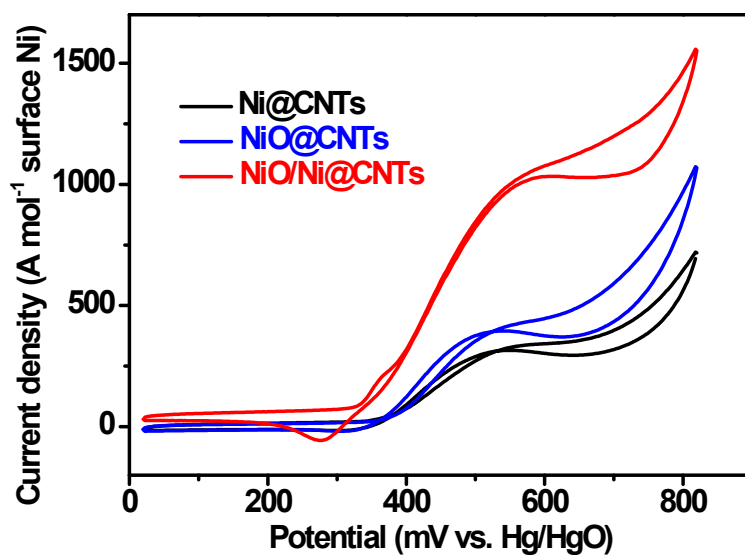


Figure S6. CVs of catalysts normalized to the surface Ni content in 1M KOH+0.5 M CH_3OH . Scan rate: 50 mV s^{-1} .

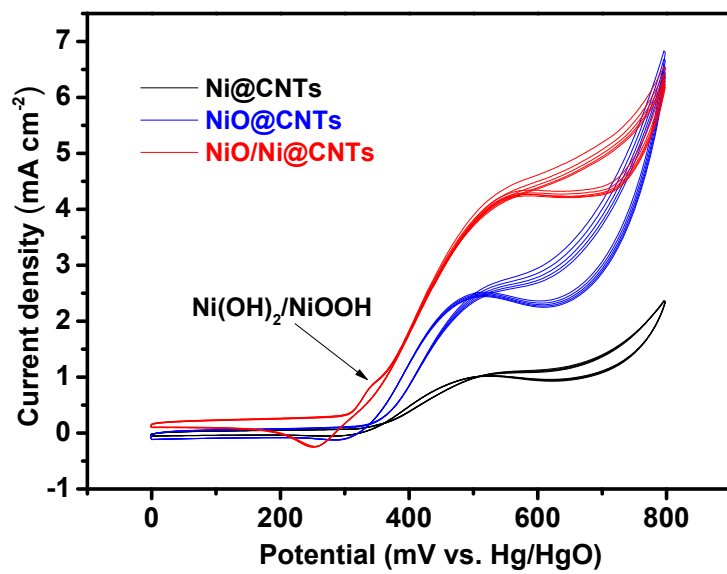


Figure S7. CVs of catalysts in the first five cycles.

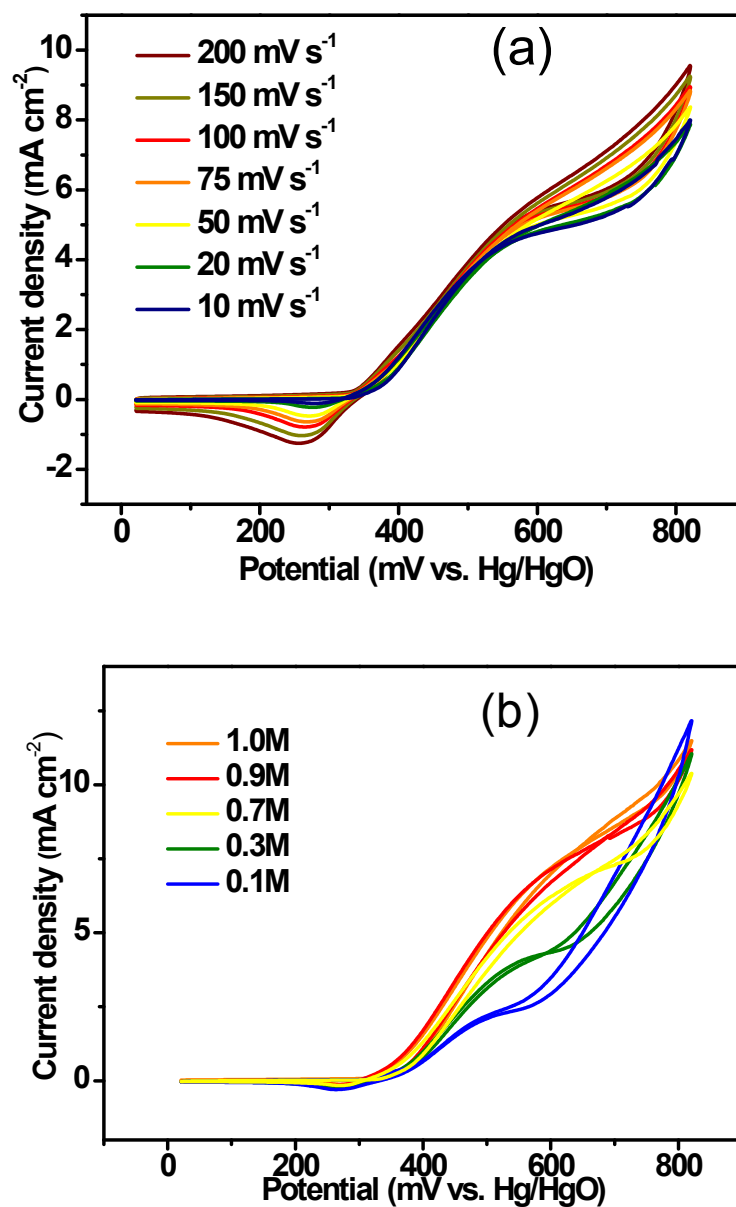


Figure S8. Current response of methanol oxidation of NiO/Ni@CNTs with the increasing scan rates in 1.0 M KOH+0.5 M methanol (a). Scan rate: 10, 20, 50, 100, 150, 200 mV s⁻¹. Current response of methanol oxidation of NiO/Ni@CNTs with the increasing concentration of methanol (b). Scan rate: 20 mV s⁻¹.

Table S1. Structural parameters of various samples.

sample	content (wt%)^{a)}	dispersion (%)^{b)}	surface content (mmol g⁻¹ cat)^{b)}	surface area (m²g⁻¹ cat)^{b)}	Particle size TEM (nm)	Particle size XRD (nm)
Ni@CNTs	3.26	4.21	0.023	0.9141	9.17	9.4
NiO@CNTs	3.76	4.50	0.045	1.1277	4.1	4.0
NiO/Ni@CNTs	3.98	4.38	0.0297	1.1616	7.93	8.0

^{a)} values determined by ICP–AES. ^{b)} values calculated based on pulse chemisorption analysis.

Table S2. Comparison of activity between catalysts in this study and reported Ni based catalysts.

Catalysts	Mass Activity (mA mg ⁻¹)	Testing Conditions		References
		Scanning rate (mV s ⁻¹)	CH ₃ OH concentration	
NiO/Ni@CNTs	2094	50	1.0 M CH ₃ OH	This work
NiO @CNTs	1328	50	1.0 M CH ₃ OH	This work
Ni@CNTs	966	50	1.0 M CH ₃ OH	This work
NiP	1490	50	1.0 M CH ₃ OH	[1]
CNT–Ni/SiC-700	1000	50	1.0 M CH ₃ OH	[2]
NiO	84	20	0.1M CH ₃ OH	[3]
NiO/CNTs	1900	50	0.5 M CH ₃ OH	[4]
NiO/N-CNFs	1800	50	1.0 M CH ₃ OH	[5]
Ni–P/RGO	117	10	0.5 M CH ₃ OH	[6]
Ni-P	60	10	0.5 M CH ₃ OH	[6]
Ni-DES	3	10	0.1M CH ₃ OH	[7]
Ni(OH) ₂ /BDD	600	5	0.47 M CH ₃ OH	[8]

References

1. Tong, Y. Y.; Gu, C. D.; Zhang, J. L.; Huang, M. L.; Tang, H.; Wang, X. L.; Tu, J. P. *J. Mater. Chem. A* **2015**, *3*, 4669-4678.
2. Xie, S.; Tong, X. L.; Jin, G. Q.; Qin, Y.; Guo, X. Y. *J. Mater. Chem. A* **2013**, *1*, 2104-2109.
3. Spinner, N.; Mustain, W. E. *Electrochim. Acta*. **2011**, *56*, 5656-5666.
4. Tong, X. L.; Qin, Y.; Guo, X. Y.; Moutanabbir, O.; Ao, X. Y.; Pippel, E.; Zhang, M. Knez, L. B. *Small* **2012**, *8*, 3390-3395.
5. Al-Enizi, A. M.; Ghanem, M. A.; El-Zatahry, A. A.; Al-Deyab, S. S. *Electrochim. Acta*. **2014**, *137*, 774-780.
6. Zhang, H.; Gu, C. D.; Huang, M. L.; Wang, X. L.; Tu, J. P. *Electrochem. Commun.* **2013**, *35*, 108-111.
7. Gu, C. D.; Huang, M. L.; Ge, X.; Zheng, H.; Wang, X. L.; Tu, J. P. *Int. J. Hydrogen Energy* **2014**, *39*, 10892-10901.
8. Hutton, L. A.; Vidotti, M.; Patel, A. N.; Newton, M. E.; Uniwin, P. R.; Macpherson, J. V. *J. Phys. Chem. C* **2010**, *115*, 1649-1658.